

Beam transport on a chip: Alternating phase focusing

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Particle accelerators









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Why dielectric-based laser accelerators?



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Why dielectric-based laser accelerators?



Breuer J., PhD dissertation (2013)

Main components:

- Electron sources: ultrafast SEMs / TEMs / custom
- Structure fabrication: nano-lithography silicon / fused silica / other materials
- In the future: laser-driven undulator?

Opportunities:

- Compact, low-cost light sources (FELs in every institute?)
- Laser period (~6 fs) → attosecond bunching → sub-fs radiation pulses?
- *In the future:* ultrafast electron diffraction/microscopy applications? Low-power EUV for inspection? **Medical treatment**?



Particle accelerators for medicine?

- Short term: compact incoherent x ray source (bremsstrahlung)
- Very long term: optical lab sized coherent x ray source
- Intermediate term: medical irradiation source:



England et al., "Dielectric laser accelerators," Rev. Mod. Phys. 86, 1337 (2014)

- Intraoperative electron beam radiation therapy (IOERT)
- Proximity radiation of tissue (minimally invasive "electron beam scalpel"?)
- Neuronal endplate treatment (Prof. Warren Grundfest, UCLA)
- New high dose rate radiation effects to be expected?

Electron accelerators with lasers - 1962







Electron Acceleration by Light Waves

A. Lohmann*

October 3, 1962

Summary

Light, particularly in the form of evanescent waves, can be employed to accelerate charged particles. Since the field strength in LASER radiation is expected to be of the order of 10^9 V/m, an accelerator of significantly reduced dimensions based upon this concept appears feasible. The proposed accelerator works on what may be defined as the time-reversed Smith-Purcell effect.



First patent filed in 1963

3,267,383 PARTICLE ACCELERATOR UTILIZING COHERENT LIGHT Adolf W. Lohmann, San Jose, Calif., assignor to International Business Machines Corporation, New York, N.Y., a corporation of New York Filed May 27, 1963, Ser. No. 283,475 9 Claims. (Cl. 328-33)

The present invention relates to particle accelerators and more particularly to a particle accelerator wherein energy is transferred to particles by means of visible or infrared light waves.

Aug. 16, 1966	A. W. LOHMANN	3,267,383
PARTICLE	ACCELERATOR UTILIZING COHERE	NT LIGHT
Filed May 27, 1963		2 Sheets-Sheet S
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4064		T
FIG.4	F	FIG.5



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A family of nanophotonic structures



<u>REVIEW</u>: England et al., "Dielectric laser accelerators," Rev. Mod. Phys. **86**, 1337 (2014)

<u>REVIEW</u>: Wootton, McNeur, Leedle, "Dielectric Laser Accelerators: Designs, Experiments, and Applications," Rev. of Accel. Sci. and Tech. **9**, 105-126 (2016)

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ACHIP: Accelerator on a Chip International Program Goals: demonstrate (1) a shoebox-sized 1 MeV accelerator & (2) photon generation



ACHIP Scientific Advisory Board:

Chan Joshi, UCLA, Reinhard Brinkmann, DESY, Tor Raubenheimer, SLAC





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ACHIP: Accelerator on a Chip International Program Goals: demonstrate (1) a shoebox-sized 1 MeV accelerator & (2) photon generation







ACHIP: Accelerator on a Chip International Program Ballistic buncher: down to 270±80 attoseconds (FWHM)



Schönenberger et al., Phys. Rev. Lett. **123**, 264803 (2019) Black et al., Phys. Rev. Lett. **123**, 264802 (2019)



ACHIP: Accelerator on a Chip International Program Inverse design of an optimized electron accelerator on a chip



Sapra et al., Science, 367, 79-83 (2020)





ACHIP: Accelerator on a Chip International Program Wakefield calculations in DLA structures



Egenolf et al., Phys. Rev. Accel. Beams 23, 054402 (2020)



ACHIP: Accelerator on a Chip International Program Diamond-coated needle-tips as high brightness sources



Tafel et al., Phys. Rev. Lett. 123, 146802 (2019)



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ACHIP: Accelerator on a Chip International Program Compact 30kV electron source



Hirano et al., Appl. Phys. Lett. 116, 161106 (2020)

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ACHIP: Accelerator on a Chip International Program Laser-modulated 3 GeV electron beam in DLA

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ACHIP: Accelerator on a Chip International Program 850 MeV/m average gradient at UCLA Pegasus

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ACHIP: Accelerator on a Chip International Program DSEY/SINABD: planned acceleration experiments

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ACHIP: Accelerator on a Chip International Program ...and more!

Schönenberger et al., Phys. Rev. Lett. **123**, 264803 (2019) Black et al., Phys. Rev. Lett. **123**, 264802 (2019)

Sapra et al., Science, 367, 79-83 (2020)

Tafel et al., Phys. Rev. Lett. 123, 146802 (2019)

Cesar et al., Comm. Phys., 1, 46 (2018)

Mayet et al., NIMA 909, 213-216 (2018)

Hirano et al., Appl. Phys. Lett. 116, 161106 (2020)

Hermann et al., Sci. Rep., 9,19773 (2019)

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Phase-synchronous acceleration

(here with optical drive fields):

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Phase-synchronous acceleration

Acceleration

Deceleration

-) Deflection ("focusing")
 - Deflection ("defocusing")

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Structure evolution

Breuer and Hommelhoff, PRL 111, 134803 (2013)

Leedle et al., Opt. Lett. 40, **18** (2015) Yousefi et al., NIMA 909, **221** (2018)

Simple fabricationAsymmetric field deflects electrons vertically

Peralta, et al. Nature 503, 91-94 (2013)

Symmetric field profile in the channel
 Fabrication (and alignment of wafers) difficult
 Laser must travel through bulk material

Structure evolution

OPEN ACCELERATING STRUCTURES

Leedle et al., Opt. Lett. 40, **18** (2015) Yousefi et al., NIMA 909, **221** (2018) P R O P O S A L for a Study of Laser Acceleration of Electrons using Micrograting Structures at the ATF (Phase I)

29 October 1989

Chen... Palmer et. al. (1989) BNL—43465 DE90 003699

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Structure evolution

"Dual pillar" structure:

- Symmetric field profile in the channel
- Simple fabrication process
 (e-beam lithography + etching)
- No nonlinear optical effects
 (laser doesn't traverse the bulk)

Palmer, SLAC-PUB-4161 (1986) Leedle et al., Opt. Lett. 40, **18** (2015) Yousefi et al., NIMA 909, **221** (2018)

Dual pillar with a distributed Bragg reflector

(For subrelativisic electrons, ~30keV)

Parameter	Size (nm)
Pillar period	660
Mirror spacing	500
Mirror plate thickness	144
Aperture width	225
Height	3000

Yousefi et al., NIMA 909, 221 (2018)

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Dual pillar with a distributed Bragg reflector

(For subrelativisic electrons, ~30keV)

Shiloh, Chlouba, Yousefi, Hommelhoff Opt. Exp. **29**, 14403 (2021)

Leedle, Ceballos, Deng, Solgaard, Fabian-Pease, Byer, Harris, Opt. Lett. **43**, 2181 (2018)

Yousefi et al., NIMA 909, 221 (2018)

Full fields of a dual-pillar structure

• "Synchronous particle" experiences only an accelerating field

• Laser illumination: symmetric from both sides $(+\hat{\mathbf{x}} \text{ and } -\hat{\mathbf{x}})$

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Full fields of a dual-pillar structure

- "Synchronous particle" experiences only an accelerating field
- Deviation from synchronicity = transverse deflection (beam defocus) •
- We're using near-field optical forces (recall: field strengths \sim 1GV/m)
- Conventional elements (quadrupoles, solenoids, einzel lenses, etc..) cannot compensate the optical defocusing forces
 - A solution: use engineered dielectric structures!

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- Adapted (Fainberg 1956) to dielectric laser acceleration under ACHIP
- In a nutshell: once the electron beam begins to defocus, flip the laser's phase, so alternate between focusing forces and defocusing forces
- In practice: gaps are introduced periodically along the structure
- Much like designing a FODO lattice, except alternate between *longitudinal* and one transverse directions (z—x here)
- The APF lattice period adjusted to beam energy + maximum beam envelope fits in the channel.

Niedermayer, Egenolf, Boine-Frankenheim, Hommelhoff, Phys. Rev. Lett. 121, 214801 (2018)

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- Adapted (Fainberg 1956) to dielectric laser acceleration under ACHIP
- In a nutshell: once the electron beam begins to defocus, flip the laser's phase, so alternate between focusing forces and defocusing forces
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NEXT: beam transport with APF (no acceleration)

Niedermayer, Egenolf, Boine-Frankenheim, Hommelhoff, Phys. Rev. Lett. 121, 214801 (2018)

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Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

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Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

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• What do we expect from an experiment?

- Low incident peak fields: electron transmission grows
- Medium incident peak fields: transmission peaks
- High incident peak fields: transmission deteriorates

Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

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Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

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Structure parameters

Channel width x length:225 nm x ~77 μmFODO periods:5 (high-contrast) / 2.5 (over-focusing)Phase jumps:10 (high-contrast) / 5 (over-focusing)

Electron beam propertiesMean electron energy:28.4 keVNormalized emittance:100 pm-radElectron pulses:400-600 fs (FWHM)Repetition rate:167 kHz

Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

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Structure parameters

Channel width x length:225 nm x ~77 μmFODO periods:5 (high-contrast) / 2.5 (over-focusing)Phase jumps:10 (high-contrast) / 5 (over-focusing)

Electron beam properties

	(NOT indicative of future prospects)
Beam current:	0.133 fA or 0.005 electron per pulse throughput
Repetition rate:	167 kHz
Electron pulses:	400-600 fs (FWHM)
Normalized emittance:	100 pm-rad
Mean electron energy:	28.4 keV

Shiloh⁺, Illmer⁺, Chlouba⁺, Yousefi, Schönenberger, Niedermayer, Mittelbach, Hommelhoff, Nature, in press

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Average beam current in DLAs

Starting from the source:

- Simply increase the laser RR (167 kHz -> 1 MHz or even 100 MHz)
- Previously in our SEM: up to 1000 e/pulse at the tip emitter -> ~1-10 e/pulse at the sample [Kozák et al., J. of App. Phys. 124, 023104 (2018)]
- Dedicated compact 30 kV source for DLA: 28 e/pulse [*Hirano et al., Appl. Phys. Lett.* **116**, 161106 (2020)]
- High-brightness needle sources Tungsten+diamond, LaB₆ nanowire, diamond pyramids, Silicon nanotips offer up to 12000 e/pulse with different parameters [A. Ceballos, DLA Applications Workshop, March 26 (2019)]
- Schemes for parallelization of DLA structures: x10, x100, x1000 channels... [Zhao et al., Photonics Research **8** 10, 1586-1598 (2020)]

More points:

• Though the average current is low, with attosecond bunching abilities we can reach high peak currents – potentially even up to kA

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• Recall that DLAs don't have to be a stand-alone solution, and can be integrated into small or large facilities (less worries about the source)

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GORDON AND BETTY

NDATION

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Open positions! Pls. get in touch.

Conclusion and outlook

Nanophotonics-based particle acceleration

- All individual elements for an accelerator demonstrated
- Peak gradient of close to 1 GeV/m demonstrated
- Waveguide-integrated feeding demonstrated
- Inverse photonics structure design demonstrated
- Net energy gain demonstrated
- Attosecond bunch train generation demonstrated
- Complex electron phase space control demonstrated: alternating phase focusing
- Design proposal of an on-chip accelerator: Niedermayer et al., Phys. Rev. App. 16, 024022 (2021)
- Soon: 1 MeV accelerator on a chip?
- New light sources, new medical devices?
- Attosecond / zeptosecond pulses feasible: e- based imaging
- ✤ Soon: more experiments at 100 MeV (at DESY) and 3 GeV (at PSI)

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